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Applicant

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Group Art Unit: 2652

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Examiner Initials	Ref. No.	Date	Document No.	Name	Class	Subclass	Filing Date If Appropriate
W	1.	2/13/01	6,187,165	Chien et al.			10/1/98
H	2.	3/19/02	6,358,392	Yang et al.			11/18/99

Examiner Initials	Ref. No.	Date	Document No.	Country	Class	Subclass	Translation YES NO
<i>W</i>	3.	6/29/00	WO 00/37715	PCT			abstract

(including author, title, Date, Pertinent Pages, Etc.)

Examiner Initials	Ref No.	Title
Y	4.	Gang Xiao et al., "Very Large Magnetoresistance in Electrodeposited Single-Crystal Bi Thin Films (Invited)," Journal of Applied Physics, Vol. 87, No. 9, May 1, 2000, pp. 4659
Y	5.	Liu et al., "Structural and Magneto-Transport Properties of Electrodeposited Bismuth Nanowires," Applied Physics Letters, American Institute of Physics, New York, Vol. 73, No. 10, September 7, 1998, pp. 1436-1438
Y	6.	Cho et al., "Large Magnetoresistance in Post-Annealed Polycrystalline and Epitaxial Bi Thin Films," J. of Magnetism and Magnetic Materials, Elsevier Science B.V., Netherlands, Vol. 239, February 2002, pp. 201-203
Y	7.	European Search Report dated August 10, 2004

EXAMINER:

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EXAMINER: Initial if citation considered, whether or not the citation conforms with MPEP 609. Draw a line through the citation if not in conformance and not considered. Include a copy of this form with next communication to applicant.

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